

Docket No.: 543822003300

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Examiner: Evan T. Pert

(PATENT)

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Srivatsa KUNDALGURKI

Application No.: 10/734,593

Filed: December 15, 2003 Art Unit: 2826

For: METHOD FOR REMOVING A RESIST MASK

WITH HIGH SELECTIVITY TO A CARBON HARD MASK USED FOR SEMICONDUCTOR

STRUCTURING

## **SUBMISSION OF REPLACEMENT DRAWING**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Submitted herewith is one sheet (three figures) of drawings for filing in the aboveidentified patent application. Kindly substitute the enclosed drawings for the drawings submitted with the originally filed application.

Dated: December 16, 2005

Respectfully submitted

Kevin R. Spivak Registration No.: 43,148

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